Front Matter: Volume 7517
Photonics and Optoelectronics Meetings (POEM) 2009

Optical Storage and New Storage Technologies

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Editors

8–10 August 2009
Wuhan, China

Organized by
Wuhan National Laboratory for Optoelectronics (China)

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Published by
SPIE

Volume 7517

Proceedings of SPIE, 0277-786X, v. 7517

SPIE is an international society advancing an interdisciplinary approach to the science and application of light.
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